# PATENT COOPERATION TREATY

From the INTERNATIONAL SEARCHING AUTHORITY			2005. 3, 18					
To: SEMICONDUCTOR ENERGY		PCT	崎					
LABORATORY CO., LTD.  398, Hase, Atsugi-shi,	WRITTEN OPINION OF THE INTERNATIONAL SEARCHING AUTHORITY  (PCT Rule 43bis.1)							
Kanagawa 2430036 Japan								
	Date of mailing (day/month/year)	15. 3. 2	2005					
Applicant's or agent's file reference 00000PCT7574	FOR FURTHER ACTION  See paragraph 2 below							
International application No. PCT/JP2004/018978 International filing date 14.12		Priority date (day/month/	•					
International Patent Classification (IPC) or both national classification and IPC Int.Cl 7 H01L 27/12, H01L 29/786, H01L 21/336, G06K 19/00								
Applicant SEMICONDUCTOR ENERGY LABORATORY CO., LTD.								
BENTCONDUCTOR ENERGY INDE	TRAIDRI CO	., шт.	·					
1. This opinion contains indications relating to the following ite	ems:							
Box No. I Basis of the opinion								
Box No. II Priority								
Box No. III Non-establishment of opinion with regard to novelty, inventive step and industrial applicability								
Box No. IV Lack of unity of invention								
Box No. V Reasoned statement under Rule 43bis.1(a)(i) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement								
Box No. VI Certain documents cited	x No. VI Certain documents cited							
Box No. VII Certain defects in the international app	Box No. VII Certain defects in the international application							
Box No. VIII Certain observations on the international application								
2. FURTHER ACTION								
If a demand for international preliminary examination is made, this opinion will be considered to be a written opinion of the International Preliminary Examining Authority ("IPEA") except that this does not apply where the applicant chooses an Authority other than this one to be the IPEA and the chosen IPEA has notified the International Bureau under Rule 66.1bis(b) that written opinions of this International Searching Authority will not be so considered.								
If this opinion is, as provided above, considered to be a written opinion of the IPEA, the applicant is invited to submit to the IPEA a written reply together, where appropriate, with amendments, before the expiration of 3 months from the date of mailing of Form PCT/ISA/220 or before the expiration of 22 months from the priority date, whichever expires later.								
For further options, see Form PCT/ISA/220.								
3. For further details, see notes to Form PCT/ISA/220.								
Date of completion of this opinion 24.02.2005								
Name and mailing address of the ISA/JP	Authorized officer		4M 3123					
Japan Patent Office	Sonoko Mi	yazaki	-m J123					
3-4-3, Kasumigaseki, Chiyoda-ku, Tokyo 100-8915, Japan	Telephone No. +81	-3-3581-1101 Ext. 3	462					

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Box	No. I	Basis of the opinion
1.		regard to the language, this opinion has been established on the basis of the international application in the language in h it was filed, unless otherwise indicated under this item.
		This opinion has been established on the basis of a translation from the original language into the following language  , which is the language of a translation furnished for the purposes of international search (under
		Rules 12.3 and 23.1(b)).
	117:44	
۷.	claime	regard to any nucleotide and/or amino acid sequence disclosed in the international application and necessary to the ed invention, this opinion has been established on the basis of:
	a. typ	e of material
		a sequence listing table(s) related to the sequence listing
	<u> </u>	
	b. for	mat of material in written format
	Ē	in computer readable form
	·	
	c. tim	e of filing/furnishing
	F	contained in the international application as filed.  filed together with the international application in computer readable form.
		furnished subsequently to this Authority for the purposes of search.
3.		In addition, in the case that more than one version or copy of a sequence listing and/or table relating thereto has been filed or furnished, the required statements that the information in the subsequent or additional copies is identical to that in the application as filed or does not go beyond the application as filed, as appropriate, were furnished.
4.	Addi	tional comments:
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citation	s and explana	tions suppor	e 43018.1(a)(1) with regard to novelty, inventive step or industrial applicability; sorting such statement		
Statement					
Novelty (N)		Claims Claims	1-30	YES NO	
Inventive step .(	(IS)	Claims Claims	1-30	YES NO	
Industrial applic	cability (IA)	Claims Claims	1-30	YES NO	
	Statement Novelty (N) Inventive step (	Statement	Statement  Novelty (N)  Claims  Claims  Inventive step (IS)  Claims  Claims  Claims  Claims	Novelty (N)         Claims Claims         1-30           Inventive step (IS)         Claims Claims I-30           Industrial applicability (IA)         Claims I-30	

## 2. Citations and explanations

D1:US 2001/0015256 A1(Semiconductor Energy Laboratory) 2001.08.23, whole document, Figs.1-9

D2: JP 2003-203898 A (SEIKO EPSON CORPORATION)

2003.07.18, whole document, Figs. 1-20

D3: US 2001/0053559 A1 (Semiconductor Energy Laboratory)

2001.12.20, whole document, Figs. 1-14

D4:WO 2003/010825 A1(SEIKO EPSON CORPORATION)

2003.02.06, whole document, Figs. 1-34

# [Claims 1-4]

The subject matter of claims 1-4 does not appear to involve an inventive step in view of the cited documents D1- D2.

D1 discloses a method for manufacturing a thin film integrated circuit device comprising the steps of: forming a peel-off layer over a substrate; forming a base film over the peel-off layer; forming a plurality of thin film integrated circuit over the base film; forming a polyimide film over the plurality of thin film integrated circuit, thereby forming the plurality of thin film integrated circuit devices; forming a groove at a boundary between the plurality of thin film integrated circuit devices; attaching a jig to an upper portion of the plurality of thin film integrated circuit devices; introducing a gas containing halogen fluoride into the groove, thereby removing the peel-off layer and separating the plurality of thin film integrated circuit devices; and removing the jig attaching to the plurality of thin film integrated circuit devices.

D2 discloses a method for manufacturing a thin film integrated circuit device comprising the steps of: forming a peel-off layer over a substrate; forming a base film over the peel-off layer; forming a plurality of thin film integrated circuit over the base film; forming a groove-at a boundary between the plurality of thin film integrated circuit devices; attaching a jig to an upper portion of the plurality of thin film integrated circuit devices; introducing liquid etchant into the groove, thereby removing the peel-off layer and separating the plurality of thin film integrated circuit devices; and removing the jig attaching to the plurality of thin film integrated circuit devices.

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#### Supplemental Box

In case the space in any of the preceding boxes is not sufficient. Continuation of: Box No.V

#### [Claim 5]

The subject matter of claim 5 does not appear to involve an inventive step in view of the cited documents D1- D2.

D2 discloses that the jig is attached using an adhesive material whose adhesive force is reduced or lost by UV light irradiation.

### [Claim 6]

The subject matter of claim 6 does not appear to involve an inventive step in view of the cited documents D1- D3.

D3 discloses forming a siloxane film over the plurality of thin film integrated circuit devices.

# [Claims 7-8]

The subject matter of claims 7-8 does not appear to involve an inventive step in view of the cited documents D1- D2.

D1 discloses that the peel-off layer contains silicon as a main component and the base film is a silicon oxide film.

### [Claim 9]

The subject matter of claim 9 does not appear to involve an inventive step in view of the cited documents D1- D2.

D2 discloses that the groove is formed by dicing or dry etching.

### [Claims 10-11]

The subject matter of claims 10-11 does not appear to involve an inventive step in view of the cited documents D1- D2.

D1 discloses that the substrate is a glass substrate and the halogen fluoride is chlorine trifluoride.

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#### Supplemental Box

In case the space in any of the preceding boxes is not sufficient. Continuation of: Box No.V

#### [Claims 12-15]

The subject matter of claims 12-15 does not appear to involve an inventive step in view of the cited documents D1- D2, D4.

D1 discloses a method for manufacturing a thin film integrated circuit device comprising the steps of: forming a peel-off layer over a substrate; forming a base film over the peel-off layer; forming a plurality of thin film integrated circuit over the base film; forming a polyimide film over the plurality of thin film integrated circuit, thereby forming the plurality of thin film integrated circuit devices; forming a groove at a boundary between the plurality of thin film integrated circuit devices; attaching a jig to an upper portion of the plurality of thin film integrated circuit devices; introducing a gas containing halogen fluoride into the groove, thereby removing the peel-off layer and separating the plurality of thin film integrated circuit devices; and removing the jig attaching to the plurality of thin film integrated circuit devices.

D2 discloses a method for manufacturing a thin film integrated circuit device comprising the steps of: forming a peel-off layer over a substrate; forming a base film over the peel-off layer; forming a plurality of thin film integrated circuit over the base film; forming a groove at a boundary between the plurality of thin film integrated circuit devices; attaching a jig to an upper portion of the plurality of thin film integrated circuit devices; introducing liquid etchant into the groove, thereby removing the peel-off layer and separating the plurality of thin film integrated circuit devices; and removing the jig attaching to the plurality of thin film integrated circuit devices.

D4 discloses an antenna on an upper portion of the plurality of thin film integrated circuit devices.

### [Claim 16]

The subject matter of claim 16 does not appear to involve an inventive step in view of the cited documents D1- D2, D4.

D2 discloses that the jig is attached using an adhesive material whose adhesive force is reduced or lost by UV light irradiation.

#### [Claim 17]

The subject matter of claim 17 does not appear to involve an inventive step in view of the cited documents D1- D4.

D3 discloses forming a siloxane film over the plurality of thin film integrated circuit devices.

#### [Claims 18-19]

The subject matter of claims 18-19 does not appear to involve an inventive step in view of the cited documents D1- D2, D4.

D1 discloses that the peel-off layer contains silicon as a main component and the base film is a silicon oxide film.

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#### Supplemental Box

In case the space in any of the preceding boxes is not sufficient. Continuation of: Box No.V

#### [Claim 20]

The subject matter of claim 20 does not appear to involve an inventive step in view of the cited documents D1- D2, D4.

D2 discloses that the groove is formed by dicing or dry etching.

#### [Claims 21-22]

The subject matter of claims 21-22 does not appear to involve an inventive step in view of the cited documents D1- D2, D4.

D1 discloses that the substrate is a glass substrate and the halogen fluoride is chlorine trifluoride.

# [Claims 23-24, 27-28]

The subject matter of claims 23-24, 27-28 does not appear to involve an inventive step in view of the cited documents D1-D4.

D4 discloses a non-contact thin film integrated circuit devices comprising: a thin film integrated circuit formed over a substrate with a base film and an antenna formed over the plurality of thin film integrated circuit devices.

D3 discloses a siloxane film over the plurality of thin film integrated circuit devices.

#### [Claims 26, 29]

The subject matter of claims 26, 29 does not appear to involve an inventive step in view of the cited documents D1-D4.

D4 discloses that the substrate is a flexible substrate, a bill or a credit card.

#### [Claims 25, 30]

The subject matter of claims 25, 30 does not appear to involve an inventive step in view of the cited documents D1-D4.

It is common knowledge technology to make an antenna of Cu, Fe, Al, etc..